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### (12) United States Patent

#### Cunningham

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### (54) CENTRAL VACUUM CLEANER MULTIPLE VACUUM SOURCE CONTROL

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- (51) **Int. Cl.**

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(2006.01)

(52) **U.S. Cl.** 

(58) Field of Classification Search

USPC ....... 15/314, 315, 319, 326, 327.6, 331, 339,

See application file for complete search history.

#### (56) References Cited

#### U.S. PATENT DOCUMENTS

1,601,531 A	9/1926	Jeannin
1,883,288 A	10/1932	Zubaty
3,088,484 A	5/1963	Marsh
3,357,039 A	12/1967	Hayward
3,382,524 A	5/1968	Sandstrom

3,477,689 A	11/1969	Berghoefer	
3,483,503 A	12/1969	Pardiso	
3,565,103 A	2/1971	Maselek	
3,570,809 A	3/1971	Stuy	
3,626,545 A	12/1971	Sparrow	
3,628,769 A	12/1971	Lee	
3,661,356 A	5/1972	Tucker	
3,663,845 A	5/1972	Apstein	
3,676,986 A	7/1972	Reiling	
3,826,464 A	7/1974	Berghofer	
3,855,665 A	12/1974	Schwartz	
3,965,526 A	6/1976	Doubleday	
3,989,311 A	11/1976	Debrey	
4,056,334 A	11/1977	Fortune	
	(Continued)		

#### FOREIGN PATENT DOCUMENTS

EP	0192469		8/1986
EP	0347223		2/1989
	(0	. •	15

(Continued)

#### OTHER PUBLICATIONS

Heritage Central Vacuum, Crush Proof Hoses Non-Electric, http://www.heritagevac.com/hosesnonelectric.html, printed Sep. 21, 2005, pp. 4, Azusa, USA.

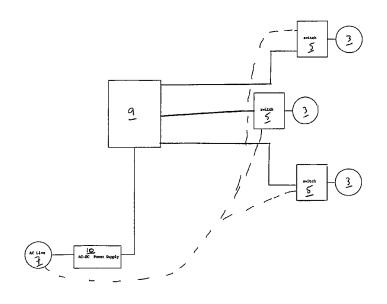
(Continued)

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#### (57) ABSTRACT

A central vacuum cleaning system has multiple vacuum sources. The multiple vacuum sources are connected through pipes to wall valves. In use a hose is plugged into one of the valves. A handle is connected to the hose. A wand extends from the handle. Attachments such as a power brush are connected to the wand. Switches apply power from one or more power sources to the vacuum sources. The application of power by the switches is controlled by a control circuit.

#### 10 Claims, 4 Drawing Sheets

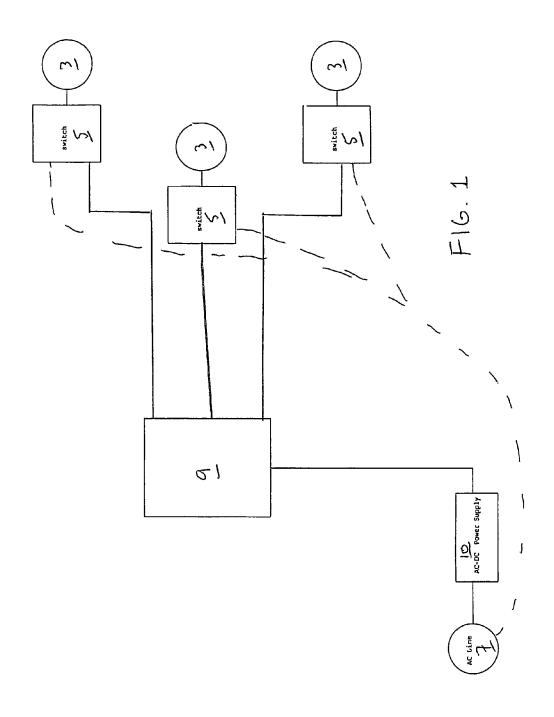


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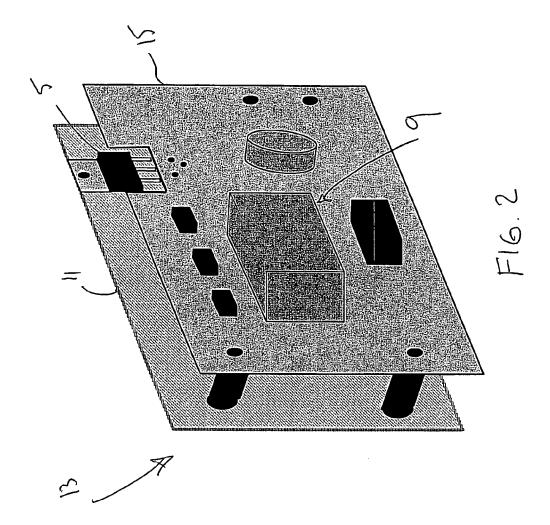
(56) Refere	ences Cited	5,479,676 A		Martin et al.
II C DATEN	T DOCUMENTS	5,504,971 A 5,512,883 A		McCormick Lane, Jr.
U.S. FAIEN	I DOCUMENTS	5,515,572 A		Hoeksra et al.
4,070,586 A 1/1978	B Breslin	5,525,842 A		Leininger
	8 Watanabe	5,542,146 A		Hoekstra et al.
	B De Brey	5,554,049 A		Reynolds
	De brey	5,560,076 A 5,568,374 A	10/1996	Leung Lindeboom et al.
	) Palmovist	5,572,767 A		Ishikawa
7 7	) Root et al. I Costanzo	5,578,795 A	11/1996	
	Rodowsky, Jr. et al.	5,606,767 A		Crienjak et al.
	2 Lindsay	5,655,884 A	8/1997	
4,368,348 A 1/198	Bichelberger et al.	5,698,957 A	12/1997	
	Chen et al.	5,713,656 A 5,722,110 A	2/1998	McIntyre et al.
	3 Kullik 4 Tucker et al 15/50.1	5,737,797 A		Rittmueller et al.
	1 Neroni et al.	5,737,798 A		Moren et al.
	4 Kutnyak	5,740,581 A		Harrelson, II
4,494,270 A 1/198	5 Ritzau et al.	5,740,582 A		Harrelson, II
	Godfrey et al.	5,747,973 A		Robitaille et al.
	5 Gansert et al.	5,753,989 A 5,813,085 A		Syverson et al. Fritz et al.
	5 Schmidt 5 MacDuff	5,815,883 A		Stein et al.
	Komatsu et al.	5,815,884 A		Imamura
4,654,924 A 4/198	7 Getz et al.	5,816,685 A	10/1998	
	7 Suchy	5,850,665 A	12/1998	
	7 Hummel	5,871,152 A D406,422 S	2/1999 3/1999	Burchard et al.
-, ,	7 Beihoff et al. 7 Liebmann et al.	5,893,194 A *		Karmel 15/314
	7 Choiniere et al.	5,896,618 A		Woo et al.
4,731,545 A 3/198	B Lerner et al.	5,917,428 A		Discenzo et al.
	8 Sumerau	5,918,728 A 5,924,163 A		Syverson Burns, Jr.
	8 Walker 8 Bigley et al.	5,924,164 A		Lindsay, Jr.
	Wang	5,926,908 A		Lindsay, Jr.
	Harkonen et al.	5,926,909 A		McGee
	Blandin	5,938,061 A		Ward et al.
	Blackman	5,945,749 A 5,983,443 A	8/1999 11/1999	Redding
	9 Forbes et al. 9 Emdy 181/231	5,987,697 A		Song et al.
	Hayden	6,011,334 A		Roland
4,991,253 A 2/199	l Rechstiner	6,029,309 A		Imamura
	Kraft et al.	6,033,082 A 6,049,143 A	3/2000 4/2000	Simpson et al.
	l Cavallero l Oberdorfer-Bogel	6,101,667 A		Ishikawa
	2 Chun	D431,335 S		Mehaffey et al.
	2 Rohn et al.	6,169,258 B1	1/2001	Roney et al.
	2 Houston	6,206,181 B1 6,218,798 B1		Syverson Price et al.
5,120,983 A 6/1992 5,125,125 A * 6/1992	2 Samaan 2 Barsacq 15/314	6,232,696 B1		Kim et al.
	3 Herron, Jr.	6,239,576 B1*	5/2001	Breslin et al 318/805
	3 Farrington	6,244,427 B1	6/2001	Syverson
	3 Rohn	6,253,414 B1		Bradd et al.
	3 Damizet	6,256,833 B1 6,323,570 B1		Steinberg Nishimura et al.
	3 Lawrence et al. 3 Guss et al.	6,336,825 B1		Seefried
	3 Fujiwara et al.	6,425,293 B1		Woodroffe et al.
	3 Dick	6,459,056 B1 6,463,368 B1		Graham
	3 Kraft et al.	6,488,475 B2		Feiten et al. Murata et al.
	3 Noeth 4 Radabaugh et al.	6,546,814 B1		Choe et al.
	Frooks et al.	6,628,019 B2	9/2003	Carroll
5,276,939 A 1/199	4 Uenishi	6,658,325 B2	12/2003	
	Blatt et al.	6,685,491 B2 6,690,804 B2		Gergek Everett
	4 Michel 4 Abe et al.	D494,332 S		Schroeter
	4 Boshler	D494,333 S		Schroeter
5,343,590 A 9/1994	4 Radabaugh	6,779,228 B2		Plomteux et al.
	4 Konotchick	6,791,205 B2		Woodbridge
	4 Radabaugh 4 Yap et al.	6,817,058 B1 6,822,353 B2		Harrelson, II Koga et al.
	+ Yap et al. 4 Dekker et al.	6,864,594 B2	3/2005	
	5 Wang	6,900,565 B2	5/2005	Preston
5,391,064 A 2/199.	5 Lopez	6,975,043 B2	12/2005	Schumacher et al.
	5 Ishikawa	6,975,993 B1	12/2005	
	5 Chadbourne et al.	7,051,398 B2		Smith et al.
	5 Ward 5 Langeland et al.	7,080,425 B2 7,114,216 B2		Smith et al. Stephens et al.
D304,014 S 11/199	Languanu et al.	7,117,210 DZ	10/2000	этериена ет ат.

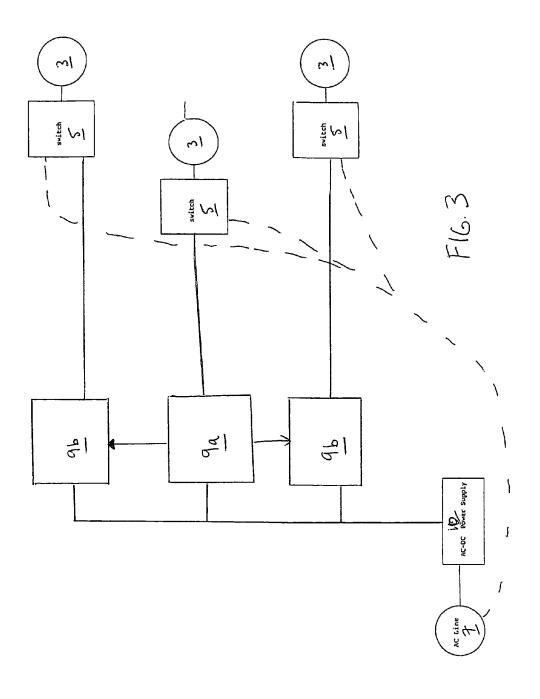
# US 8,732,895 B2 Page 3

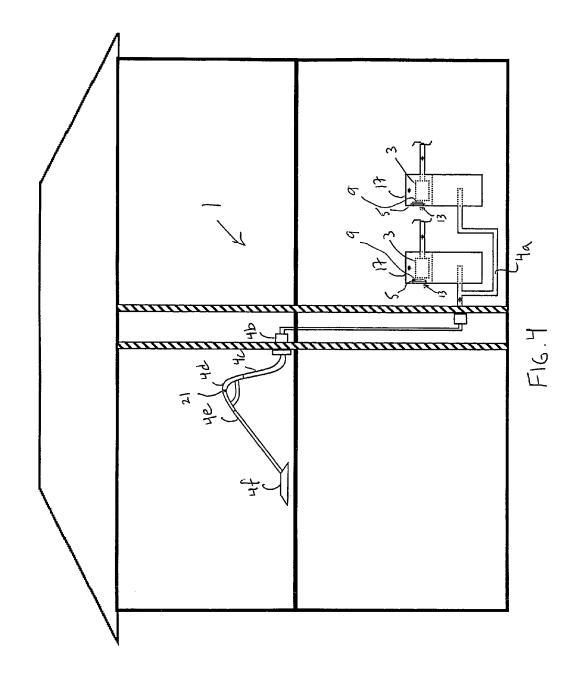
(56)	Referer	nces Cited	EP	0773619	5/1997	
			GB	2281507	3/1995	
	U.S. PATENT	DOCUMENTS	GB	2288115	10/1995	
			JP	53-58160	5/1978	
7,122,921	B2 10/2006	Hall et al.	JP	53-128158	11/1978	
7,237,298		Reindle et al.	JP	60-26494	9/1985	
7,269,877		Tondra et al.	JP	64-049526	2/1989	
7,328,479		Willenbring	JP	2-152420	6/1990	
7,331,083		Overvaag et al.	JP	2-152419	12/1990	
7,342,372		Jonsson et al.	JP	4-017830	1/1992	
7,363,679		Zimmerle et al.	JP	5-003839	1/1993	
7,403,360		Cunningham et al.	JP	5-317213	3/1993	
7,406,744		Bruneau	JP	6-277167	10/1994	
2002/0001190		Everett	JP	7-095944	11/1995	
2002/0127916		Zhang	JP	7-322980	12/1995	
2002/0152576		Murray et al.	JP	8-033596	2/1996	
2003/0044243	A1* 3/2003	Tisdale 406/28	JP	8-117165	5/1996	
2003/0140443			JP	8-065876	8/1996	
2003/0196293			JP	8-240329	9/1996	
2004/0031506			JP	9-149871	10/1997	
2004/0049868			JP	10-094504	4/1998	
2004/0135537		Conner et al 318/701	JP	2000-116577	4/2000	
2004/0144633		Gordon et al.	JP	2001-137158	5/2001	
2004/0150271		Koga et al.	JP	2002-078656	3/2002	
2004/0172782		Smith et al 15/314	JP	2002-320577	5/2002	
2004/0177468		Smith et al.	JP	2003-235767	8/2003	
2004/0231090		Kushida et al 15/326	JP	2005-102465	4/2005	
2004/0261211		Overvaag et al.	JP	2009-058919	3/2009	
2005/0022329		Harman et al.	WO	97/37423	10/1997	
2005/0022323		Roney et al.	WO	97/41631	11/1997	
2005/0055795		Zeiler et al 15/353	WO	98/35160	8/1998	
2005/0055755		Cunningham et al.	WO	99/09875	3/1999	
2005/0236012		Josefsson et al.	WO	99/56606	11/1999	
2005/0230012		Hayes et al.	WO	00/64323	11/2000	
2005/0254185		Cunningham	WO	2005/031169	2/2005	
			WO	2007/017057	2/2007	
2007/0283521		Foster et al.		OTHER PI	JBLICATIONS	
2008/0066252		Herron, Jr.		OTTLERT	DBLIC: II IOI IS	
2008/0222836		Cunningham	New Ce	ntral Vacuum Broaks I	Home Automation Barrier, Bus	inacc
2008/0301903	A1 12/2008	Cunningham et al.			ione Automation Barrier, Bus	incss
				ed Feb. 26, 2002.		
FC	REIGN PATE	NT DOCUMENTS			eAir RecoupAerator 200DX En	
					Manual and Installation Guide	, Jan.
EP	0552978	7/1993	24, 2006	pp. i-iv, 1-41 Athens,	USA.	
EP	0499235	9/1995				
EP	0711023	5/1996	* cited 1	by examiner		
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May 27, 2014







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### CENTRAL VACUUM CLEANER MULTIPLE VACUUM SOURCE CONTROL

This application claims priority from, and is entitled to the benefit of the filing date of, U.S. patent application Ser. No. 60/724,289 entitled CENTRAL VACUUM CLEANER MULTIPLE VACUUM SOURCE CONTROL filed 7 Oct. 2005, the content of which is hereby incorporated by reference into the detailed description hereof.

#### FIELD OF THE INVENTION

The invention relates to central vacuum cleaning systems.

#### BACKGROUND OF THE INVENTION

Central vacuum cleaning systems were originally quite simple. One placed a powerful central vacuum source external to the main living space. The source was connected through interior walls to a long flexible hose that terminated 20 in a handle and nozzle. When an operator desired to use the system, the operator went to the source and turned it on. The operator then went inside, picked up the handle and directed the nozzle to an area to be cleaned.

Although many elements of the basic system remain, many 25 improvements have been made. Rigid pipes typically run inside interior walls to numerous wall valves spaced throughout a building. This allows an operator to utilize a smaller hose while covering an equivalent space. This is an advantage as the hose can be quite bulky and heavy.

Various communication systems have been developed. Some systems sense sound or pressure in the pipes to turn the vacuum source on or off, see for example U.S. Pat. No. 5,924,164 issued 20 Jul. 1999 to Edward W. Lindsay under title ACOUSTIC COMMUNICATOR FOR CENTRAL 35 VACUUM CLEANERS. Other systems run low voltage wires between the source and the wall valve. The source can be turned on and off at a wall valve by a switch that may be activated by insertion or removal of the hose. The hose may also contain low voltage wires to allow the source to be 40 controlled from a switch in the handle, see for example U.S. Pat. No. 5,343,590 issued 6 Sep. 1994 to Kurtis R. Radabaugh under title LOW VOLTAGE CENTRAL VACUUM CON-TROL HANDLE WITH AN AIR FLOW SENSOR. The switch can be a simple toggle switch, or a more sophisticated 45 capacitive switch.

The low voltage wires running along the pipes can be replaced by conductive tape or the like on the pipes, see for example U.S. Pat. No. 4,854,887 issued 8 Aug. 1989 to Jean-Claude Blandin under title PIPE SYSTEM FOR CENTRAL 50 SUCTION CLEANING INSTALLATION. Separate low voltage conductors in the walls can be avoided altogether by using mains power wires to transmit communication signals between the wall valve and the source, see for example U.S. Pat. No. 5,274,878 issued 4 Jan. 1994 to Kurtis R. Radabaugh, 55 et al. under title REMOTE CONTROL SYSTEM FOR CENTRAL VACUUM SYSTEMS. A handheld radio frequency wireless transmitter can be used by an operator to turn the source on or off, see for example U.S. Pat. No. 3,626,545 issued 14 Dec. 1971 to Perry W. Sparrow under title CENTRAL VACUUM CLEANER WITH REMOTE CONTROL.

Line voltage can be brought adjacent the vacuum wall valves and connected to the handle through separate conductors, or integrated spiral wound conductors on the hose. Line voltage can then be brought from the handle to powered 65 accessories, such as an electrically-powered beater bar, connected to the nozzle. Line voltage can be switched on and off

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to the powered accessory using the same switch in the handle that controls the source. Alternatively, the powered accessory may have its own power switch.

A control module mounted to the central vacuum unit is typically used to control the vacuum source. In an effort to increase suction, it is known to utilize two motors in a central vacuum unit under the control of the control module.

Improvements to, or additional or alternative features for, central vacuum cleaning systems are desirable.

#### SUMMARY OF THE INVENTION

In a first aspect, the invention provides a central vacuum cleaning system including a plurality of vacuum sources, a control circuit, and a plurality of switches. Each switch is associated with a respective one of the vacuum sources. The control circuit is adapted to control the switches. Each switch is adapted to apply power to its associated vacuum source in accordance with control from the control circuit.

The control circuit may be a plurality of control circuits with each control circuit associated with a respective one of the vacuum sources and one of the control circuits adapted to act as a master control circuit while the remaining control circuits are adapted to act as slave control circuits such that each slave control circuit is adapted to control its associated switch under control of the master control circuit.

Each switch may be a continuously variable control switch that is able to apply a continuously variable amount of power. Each switch may include a triac. Each switch may be mounted on a distinct heat sink. Each switch and the vacuum source with which it is associated may be mounted in a separate central vacuum unit.

The master control circuit may be adapted to control the slave control circuits in accordance with a master soft start function to limit instantaneous total inrush current of the vacuum sources. The master control circuit and slave control circuits may be adapted for master slave control using wireless RF communication.

In a second aspect the invention provides a method of operating multiple vacuum sources in a central vacuum cleaning system. The method includes associating a plurality of switches with the vacuum sources. Each switch is associated with a respective one of the vacuum sources. The method also includes controlling the switches using a control circuit to apply power to the vacuum sources.

Controlling the switches using a control circuit may include controlling the switches using a plurality of control circuits with the method further including associating each control circuit with a respective one of the switches. Using a plurality of control switches may include controlling the switches to limit instantaneous total inrush current to the vacuum sources.

Other aspects of the invention will be evident from the principles contained in the description and drawings herein.

#### BRIEF DESCRIPTION OF THE DRAWINGS

For a better understanding of the present invention and to show more clearly how it may be carried into effect, reference will now be made, by way of example, to the accompanying drawings that show the preferred embodiment of the present invention and in which:

FIG. 1 is a control schematic of a preferred embodiment of a central vacuum cleaning system.

FIG. 2 is a perspective view of a preferred embodiment of a control module for use in the central vacuum cleaning system of FIG. 1.

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FIG. 3 is a control schematic of a preferred embodiment of a central vacuum cleaning system.

FIG. 4 is a cross-section of a structure incorporating a preferred embodiment of a central vacuum cleaning system.

#### DETAILED DESCRIPTION OF THE PREFERRED **EMBODIMENT**

Referring to FIGS. 1 and 4, a central vacuum cleaning system 1 has multiple vacuum sources 3. The multiple vacuum sources 3 are connected through pipes 4a to wall valves 4b. In use a hose 4c is plugged into one of the valves 4b. A handle 4d is connected to the hose 4c. A wand 4e extends from the handle 4d. Attachments 4f such as a power brush are connected to the wand 4e. Switches 5 apply power from one 15 or more power sources 7 to the vacuum sources 3. The application of power by the switches 5 is controlled by a control circuit 9. The control circuit 9 ordinarily operates off low voltage DC while the vacuum source 3 typically operates from AC line voltage. Accordingly an AC-DC power supply 20 10 is provided for the control circuit 9.

Referring to FIG. 2, each switch 5 is mounted on a heat sink 11. Each switch 5 is preferably a continuously variable switch 5, such as a solid state triac, that applies a continuously variable amount of power to the vacuum source 3 under the 25 control of the control circuit 9. This allows for such features as variable speed. The control circuit 9 may be made up of discrete components; however, preferably the control circuit 9 will be based on a microcontroller and related circuitry. The various control functions of the microcontroller are imple- 30 mented through instructions stored in a memory of the microcontroller or a separate memory.

Using multiple vacuum sources can increase the suction of a central vacuum cleaning system. Using multiple switches 5 can avoid heat and power limitations of a single switch implementation for multiple vacuum sources. Use of a single control circuit 9 and multiple switches 5 can minimize the components required to implement a multiple vacuum source cleaning system.

Referring to FIG. 3, each of the switches 5 can be con- 40 trolled by its own control circuit 9 with one control circuit acting as a master control circuit 9a for the other control circuits 9b. This allows for manufacture of a single control circuit 9 for either master or slave operation. The designation of master and slave can be easily implemented in many ways, 45 such as for example, through respective DIP switches, not shown, in the control circuit 9.

Referring again to FIG. 2, a switch 5 and a control circuit 9 may be incorporated in a single control module 13. The control module 13 also includes heat sink 11. The control circuit 50 9 is mounted on a printed circuit board 15. The switch 5 is mounted on the printed circuit board 15 and the heat sink 11.

Referring to FIG. 4, each switch 5 and the vacuum source 3 it controls may be in a separate central vacuum unit 17. As 13 from the configuration of FIG. 2. The switches 5 could be separately implemented in distinct central vacuum units 17 and controlled from a single control circuit 9 as shown in FIG. 1. Use of multiple control circuits 9 configured in master slave relationships allows each control circuit 9 to utilize its own 60 intelligence for functions such as soft start.

Preferably the master control circuit 9a has a master soft start function that allows for coordinated start of the vacuum sources 3. As the vacuum sources 3 are drawing power under the application of multiple switches, it is possible to apply full 65 power to each vacuum source 3. If all sources 3 are started together then the total inrush current can be significant. A

master soft start function in the control circuit 9 can be implemented to limit instantaneous total inrush current in different ways. For example, the switches 5 can be controlled to apply power to the vacuum sources 3 one after the other, or to apply less power to each vacuum source 3 while starting multiple vacuum sources 3. A combination of these could also be used.

Communication between the control circuits 9a, 9b could be implemented using wired or wireless RF communication. Wireless RF communication may be particularly beneficial where respective control circuits 9 are in distinct central vacuum units.

The starting or change in speed of additional vacuum sources 3 could be instigated by a user. For example a control 21 could be provided on the hose handle 4d for the user to request more or less suction. This is communicated to the master control circuit 9a. Preferably communication from the handle 4d to the circuit 4a is through wireless RF; however, other wired or wireless communication means may be used.

It will be understood by those skilled in the art that this description is made with reference to the preferred embodiment and that it is possible to make other embodiments employing the principles of the invention which fall within its spirit and scope as defined by the following claims.

I claim:

- 1. A central vacuum cleaning system comprising:
- a) a plurality of vacuum sources connected to provide parallel suction forces, each vacuum source comprising a vacuum motor,
- b) a control circuit, and
- c) a plurality of switches, each switch associated with a respective one of the vacuum sources,

wherein the control circuit is adapted to control the switches, and each switch is adapted to apply electrical power to its associated vacuum source in accordance with control from the control circuit, and wherein the control circuit is connected independently to each switch and configured to control each switch independently to apply a soft start function in which the application of electrical power to the plurality of vacuum sources is coordinated to limit instantaneous total inrush current of the vacuum sources by a combination of applying power to the vacuum sources one after the other and ramping up power applied to multiple vacuum sources during startup.

- 2. The system of claim 1 wherein:
- the control circuit is a plurality of control circuits and each control circuit is associated with a respective one of the vacuum sources and one of the control circuits is adapted to act as a master control circuit while the remaining control circuits are adapted to act as slave control circuits such that each slave control circuit is adapted to control its associated switch under control of the master control circuit.
- 3. The system of claim 2 wherein the master control circuit shown in FIG. 4, the switches 5 are part of a control module 55 is adapted to control the slave control circuits to implement the soft start function to limit instantaneous total inrush current of the vacuum sources.
  - 4. The system of claim 2 wherein the master control circuit and slave control circuits are adapted for master slave control using wireless RF communication.
  - 5. The system of claim 1 wherein each switch is a continuously variable control switch that is able to apply a continuously variable amount of power.
  - 6. The system of claim 5 wherein each switch comprises a triac.
  - 7. The system of claim 1 wherein each switch is mounted on a distinct heat sink.

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8. The system of claim 7 wherein each switch and the vacuum source with which it is associated are mounted in a separate central vacuum unit.

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- 9. A method of operating multiple vacuum sources, each vacuum source comprising a vacuum motor and connected to 5 provide a suction force in parallel with the other vacuum sources, in a central vacuum cleaning system, the method comprises:
  - associating a plurality of switches with the vacuum sources, each switch associated with a respective one of 10 the vacuum sources; and
  - independently controlling the switches using a control circuit to apply electrical power to the vacuum sources, wherein each switch is controlled independently to coordinate the application of electrical power to the plurality 15 of vacuum sources to limit instantaneous total inrush current of the vacuum sources by a combination of applying power to the vacuum sources one after the other and ramping up power applied to multiple vacuum sources during startup.
- 10. The method of claim 9 wherein controlling the switches using a control circuit includes controlling the switches using a plurality of control circuits and the method further comprises associating each control circuit with a respective one of the switches.